RESEARCH PAPER

The effects of wall roughness on the methane fow in nano‑channels using non‑equilibrium multiscale molecular dynamics simulation

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Abstract This paper presents a non-equilibrium multiscale molecular dynamics simulation method to investigate the effects of periodic wall surface roughness on the structure and mass transfer of methane fuid through the silicon nano-channels. In order to accurately capture the trajectories and microstructure of methane nano-fuidics, the present modifcation of OPLS fully atomic model is employed. Meanwhile, we introduce the corresponding coarse-grained model to solve the problem of wall–fuid interaction for methane Poiseuille fow within silicon atomic walls using the classical Lorentz–Berthelot mixing rules. The geometries of the upper wall roughness are modeled by rectangular waves with different amplitudes and wavelengths. The three-dimensional number densities of C (H) atom and kinetic energy distribution plots give a clear observation of the impacts of surface roughness on the localization microinformation of methane fuid. Moreover, the slip length of fuid over rough surface decreases with the increase in amplitude. The diffusion coefficients appear anisotropic, and the radial distribution functions decrease with the increase in the amplitude. These properties should be taken into account in the design of energy-saving emission reduction nano-fuidic devices. All numerical results also indicate that the presented method not only can well solve the issue of wall–fuid interactions, but also could accurately predict the micro-information and dynamic properties of methane Poiseuille flow.

 \boxtimes Jie Ouyang jieouyang@nwpu.edu.cn **Keywords** Multiscale · Molecular dynamics · Coarsegrained · Lorentz–Berthelot · Poiseuille fow · Roughness

1 Introduction

In recent decades, considerable attention has been focused on the rough nano-channel walls in fuid mechanics and contact mechanics. In order to understand the atomic processes of fuids occurring at the rough solid interface of two materials, the scientifc community attempts to bridge models at different scales through restudying the classical theory (Bhushan et al. [1995;](#page-15-0) DelRio et al. [2005;](#page-15-1) Giannakopoulos et al. [2014](#page-15-2); Granick [1991](#page-15-3); Kasiteropoulou et al. [2012](#page-16-0); Sparreboom et al. [2010\)](#page-16-1). Moreover, the theoretical and experimental studies have been carried out in innovative technological applications and various engineering devices, such as friction and lubrication, drug delivery, water desalination and purification (Asproulis et al. [2012](#page-15-4); Bernardo et al. [2009](#page-15-5); Bhushan [2000;](#page-15-6) Choi et al. [2008](#page-15-7); Corry [2008;](#page-15-8) Gargiuli et al. [2006;](#page-15-9) Kumar et al. [2008](#page-16-2); Liakopoulos et al. [2016;](#page-16-3) Mantzalis et al. [2011;](#page-16-4) Menezes et al. [2013](#page-16-5); Wang et al. [2007\)](#page-16-6). However, experimental researches at the atomic scale (few atomic diameters) are diffcult to accomplish and, thus, atomistic molecular dynamics (MD) simulation techniques play a very important role in these felds that cannot be accessed by experiment. Although many studies of micro- and nano-fows were reported using the MD simulations in the literature (Allen and Tildesley [1989](#page-15-10); Cao et al. [2009;](#page-15-11) Delhommelle and Evans [2001a,](#page-15-12) [b](#page-15-13); Hartkamp et al. [2012](#page-15-14); Jiang et al. [2016a](#page-16-7); Karniadakis et al. [2006;](#page-16-8) Kim and Strachan [2015;](#page-16-9) Ranjith et al. [2013](#page-16-10); Svoboda et al. [2015\)](#page-16-11), there are still numerous problems to be resolved. First, at the atomic scale, because any solid surface is intrinsically rough on the micro- and nanoscale,

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how to describe the roughness of nano-channel walls is the urgent need to be addressed (Cao et al. [2009;](#page-15-11) Menezes et al. [2013](#page-16-5)). Second, the classical no-slip condition breaks down when downsizing to the nanoscale (Asproulis and Drikakis [2011](#page-15-15); Karniadakis et al. [2006\)](#page-16-8). Furthermore, the classical Lorentz–Berthelot (L–B) mixing rules fail for the complex atomistic fuids fow through the roughness nano-channel walls (Kong [1973\)](#page-16-12), due to the fact that the potential function of complex atomistic models is inconsistent with the wall, such as water, methane and methyl alcohol.

The effect of roughness of wall is of particular importance in nano-fows, since the various rough wall structures induce complex atom force at the near wall, which will affect the fow and mass transfer. Several classifcations of rough wall structures have been available in the literature (Cao et al. [2006b](#page-15-16); Galea and Attard [2004](#page-15-17); Jabbarzadeh et al. [2000;](#page-15-18) Kim and Darve [2006;](#page-16-13) Kim and Strachan [2015](#page-16-9); Kumar et al. [2011;](#page-16-14) Malijevský [2014](#page-16-15); Mo and Rosenberger [1990;](#page-16-16) Noorian et al. [2014;](#page-16-17) Priezjev [2007](#page-16-18); Sbragaglia et al. [2006;](#page-16-19) Sofos et al. [2010;](#page-16-20) Svoboda et al. [2015](#page-16-11); Zhang [2016a](#page-16-21); Ziarani and Mohamad [2006\)](#page-16-22). The impacts of sinusoidally and randomly roughened wall on momentum transfer of gas argon were studied using MD simulations by Mo and Rosenberger ([1990\)](#page-16-16). The research of Jabbarzadeh et al. (2000) (2000) demonstrated that the slip length of flow of liquid hexadecane increases at near sinusoidal-wall channel with the increase in the roughness period. Later, Priezjev [\(2007](#page-16-18)) defned randomly and periodically roughened wall that depended on the kind of forces of the wall atoms, and discussed the relation between the variation of slip length and the roughness amplitude of the wall surface. Noorian et al. ([2014\)](#page-16-17) reported the effect of wall roughness on the Poiseuille flow behavior of liquid argon through the randomly and periodically roughened wall using the non-equilibrium MD simulations. The effects of surface roughness on squeeze-flm damping for three different random and periodical surfaces were discussed by Kim and Strachan [\(2015](#page-16-9)). But these rough walls were implemented rather complex in numerical simulation. In particular, the randomly rough wall is not a quantitative analysis of the wall roughness.

The periodical and rectangular waves are usually considered as a key pattern in depicting the roughness of nanochannel walls and are further used to investigate the various properties (such as transport properties, potential distribution, velocity fuctuations and wetting properties) of fuids in the nano-channels (Cao et al. [2006a](#page-15-19); Kim and Darve [2006;](#page-16-13) Kumar et al. [2011;](#page-16-14) Sofos et al. [2009a](#page-16-23),[b,](#page-16-24) [2010,](#page-16-20) [2016](#page-16-25); Zhang [2016a](#page-16-21)). Kim and Darve ([2006\)](#page-16-13) indicated that the maximum magnitude of the polarization density inside the groove is higher than for the smooth wall, and the fow rate decreases with an increasing amplitude and a decreasing period of surface roughness. Cao et al. [\(2006a,](#page-15-19) [b](#page-15-16)) reported that the velocity of gaseous argon decreases near the submicron platinum wall as the roughness amplitude increases. Sofos et al. [\(2009a](#page-16-23), [b](#page-16-24), [c,](#page-16-26) [2010](#page-16-20), [2012](#page-16-27) and [2016](#page-16-25)) demonstrated the effects of periodic wall roughness on the fow of liquid argon through krypton nano-channels and discussed the transport properties and slip length near the rough wall. Kumar et al. ([2008,](#page-16-2) [2011](#page-16-14)) discussed the wetting properties of LJ atomistic fuid systems by Monte Carlo simulation at geometrically rough interfaces. Zhang ([2016a](#page-16-21), [b\)](#page-16-28) studied the effects of wall surface roughness on the fuid mass fow rate through a nano-slit pore in the Poiseuille flow using the flow factor approach model.

It should be noted that all the researches mentioned above are mainly confned to rough wall for simple Lennard-Jones (LJ) fuid using traditional numerical methods. Some microstructural information (distribution of atom or charge) of complex fuid (water or methane) will be lost. The interaction of wall–fuid was supposed to be LJ potential, where the parameters were determined by the fuid (generally independent of the wall material except the research of Sofos et al. [\(2016](#page-16-25)) and Cao et al. ([2006a](#page-15-19))). This leads to the strength of wall–fuid interaction independent on the material of wall. However, the properties of wall material should not be ignored, since it determines the wall–fuid interaction, which characterizes a wetting (weak interaction of wall–fuid) or a non-wetting (strong interaction of wall–fuid) surface (Cao et al. [2009\)](#page-15-11). The research of Priezjev et al. [\(2005](#page-16-29)) indicated that the larger peak maxima and more oscillations of the density profle are generated near wall, while the wall–fuid interaction increases. Asproulis and Drikakis ([2011\)](#page-15-15) reported the effects of the surface stiffness and wall particles' mass on the slip length. To the best of our knowledge, studies of the effect of rough wall on the methane nano-fuidics are scarce because the interaction of wall–fuid depends on the properties of wall material. Though the viscosity of different resolution-level methane models has been studied by Jiang et al. [\(2016a\)](#page-16-7) using Poiseuille fow in the silicon nano-channels, it is very important to study the impacts of wall roughness on the flow behavior and microstructural properties in the nanochannels, which will be helpful for the design of energysaving emission reduction nano-fuidic devices, since methane is considered as a very key fuel with environmental advantages and industrial importance (Schiermeier [2006\)](#page-16-30).

In order to explore the impacts of silicon atomic wall roughness on microstructural and dynamical properties of complex methane fuid in the rough nano-channels, we present a non-equilibrium multiscale molecular dynamics (MSMD) method in this work. As a promising multiscale method, it plays a key role in investigating the complex molecular fuid systems (Jiang et al. [2016a;](#page-16-7) Mashayak and Aluru [2012a](#page-16-31), [b;](#page-16-32) Noid [2013\)](#page-16-33) The advantage of this method is that the potential function of the coarse-grained (CG)

fuids and wall atoms is always consistent, which ensures the validity of the classical L–B mixing rules for solving the problem of wall–fuid interaction. Moreover, the potential of mean force of CG model is in good agreement with the corresponding fully atomistic model (Noid [2013;](#page-16-33) Shell [2008](#page-16-34)), which ensures the strength of wall–CG interaction close to realistic interaction of wall–fuid. It is useful for observing the slip length of fuid through the rough nanochannel walls. Furthermore, the non-equilibrium MSMD method can be used not only to tackle the physical boundary, but also to capture the micro-information of methane nano-fuidics, such as localization atomic density distributions (C and H atom), localization velocity distribution and radial distribution functions (RDFs) $g_{CC}(r)$, $g_{CH}(r)$ and $g_{HH}(r)$. For these reasons, the non-equilibrium MSMD method is very suitable for investigating the effect of wall roughness on the microstructural and dynamical properties of complex methane fuid in nano-channels.

The primary goal of this work is to investigate the infuence of the wall roughness on microstructural information and dynamical properties of methane fuid through the nano-channels in the Poiseuille fow using non-equilibrium MSMD simulations. In order to exhibit the advantage of MSMD in studying the effect of rough wall on the fuid atom behavior of the rough nano-channel walls, detailed number density distribution of C (H) atom and microstructural properties are discussed. To demonstrate the methane fuid molecules trapped into cavities of rough walls, we trace the trajectories of the trapped methane fuid molecule in the cavities using snapshots for different roughness of walls. The kinetic energy distributions are calculated over a three-dimensional computational grid inside the nanochannel in order to reveal the localization fuid velocity close to and inside the rectangular grooves. Furthermore, the effects of nano-channel walls roughness on the detailed temperature profle, velocity profle, slip length and diffusion coefficients of methane Poiseuille flow are also discussed by altering the amplitude or wavelength.

The rest of this paper is organized as follows. In Sect. [2,](#page-2-0) our models and simulation method are given. In particular, the implementation about how to describe the nano-channel walls roughness and solve the problem of wall–fuid interaction is introduced in detail. Next, simulation results are presented and discussed in Sect. [3.](#page-5-0) Finally, we draw conclusions from the present work and show some directions for future work in Sect. [4](#page-13-0).

2 Models and simulation details

A non-equilibrium MSMD simulation is conducted to study the detailed atomic behavior of methane Poiseuille flow within silicon atomic nano-channel. The methane

molecules are placed by a face-centered cubic lattice between the two silicon atomic walls at a certain distance from each other in the *z*-direction.

2.1 Physically rough wall models

Each wall is comprised of four layers of silicon atoms (each layer consisting of 240 silicon atoms). The wall atoms are placed and fxed in an ABAB stacking, since the ABAB stacking is the lowest energy confguration (Kamal et al. [2013\)](#page-16-35). The lower wall of the nano-channels is smooth. For simplicity, the rough upper wall is constructed by "anchoring" extra wall atoms on the smooth wall to form periodically rectangular wave with different amplitudes and wavelengths. For a physically rough wall, we intuitively expect that the height of the surface should vary with lateral position. Therefore, the "anchoring" extra wall atoms are placed by $\Delta z(x)$ according to the following formula for the nano-channel upper wall surfaces:

$$
\Delta z(x) = \begin{cases} 2A_i, & 0 < x \le \lambda_j/2, \\ 0, & \lambda_j/2 < x \le \lambda_j, \end{cases}
$$
 (1)

where $A_i(i = 1, 2, 3)$ and $\lambda_i(j = 1, 2, 3, 4, 5)$ are characteristics of the roughness, respectively, representing the amplitude and wavelength of the periodically rectangular wave nano-channel walls. In this work, we consider three amplitudes ($A_i = \{0.54 \sigma, 1.07 \sigma, 1.62 \sigma\}$) and five wavelengths $(\lambda_j = \{1.07 \sigma, 2.15 \sigma, 4.31 \sigma, 6.45 \sigma, 12.84 \sigma\})$ for the periodic roughness of upper walls (e.g., $\lambda_2 = 2.15 \sigma$ and A_2 =[1](#page-2-1).07 σ are given in Fig. 1). The periodic boundary

Fig. 1 Schematic of the interactions of fuid–fuid and wall–fuid using non-equilibrium MSMD simulation. Also shown nanochannel models for periodic roughness ($\lambda_2 = 2.15 \sigma$, $A_2=1.07 \sigma$) of the upper walls. The coarse-graining process and the high of nano-channels are given. Channel dimensions are $L_x \times L_y \times L_z = 12.4 \sigma \times 10.3 \sigma \times 12.4 \sigma$

conditions are applied in the *x*- and *y*-directions only. To keep consistent with the periodicity, the length of the simulation box in the *x*-direction should be chosen in such a way that it accommodates an integer number of full rectangular wave depending on the wavelength λ_i .

2.2 Methane fuid models

The optimized potential for liquid simulation (OPLS) model has been reported by Jorgensen and Tirado-Rives since 1988 (Jorgensen and Tirado-Rives [1988\)](#page-16-36). And the modifcation of OPLS (MOPLS) model was given by Jiang et al. for studying the structural and dynamical properties of dense methane fuid at the low-temperature domains (Jiang et al. $2016b$). The potential function of fully atomistic methane model can be given as

$$
u(r) = \sum_{\alpha,\beta} \sum_{i \in \alpha, j \in \beta} \left(4\varepsilon_{ab} \left(\left(\sigma_{ab} / r_{ij} \right)^{12} - \left(\sigma_{ab} / r_{ij} \right)^{6} \right) + q_i q_j / 4\pi \varepsilon_0 r_{ij} \right) \tag{2}
$$

where ε_0 , ε , σ , q and r_{ij} represent the permittivity of vacuum, the depth of the interaction energy well, molecular diameter, point charge and the distance between atoms *i* and *j*, respectively. *a* and *b* denote different types of atoms (C and H). The subscripts α and β are used to distinguish the interactions between different molecules. The bond length of C–H is $l_{\text{CH}} = 1.087 \text{ Å}$ in MOPLS model. The charges appearing in the potential function are $q_C = -4q_H = -0.572 e$. All other details of MOPLS are given in Table [1.](#page-3-0)

Table 1 Potential parameters of fully atomic methane model used in this study (Jiang et al. [2016b\)](#page-16-37)

| TYPE | Parameter | C-C | C-H | $H-H$ |
|--------------|-------------------------------------|------|-------|-------|
| MOPLS | $\frac{\varepsilon}{k_B(\text{K})}$ | 46.8 | 17.17 | 6.30 |
| | $\sigma(\AA)$ | 3.45 | 3.06 | 2.67 |

To solve the issue of wall–fuid interaction, the classical L–B mixing rule is employed in this work. The MOPLS is inconsistent with the silicon atoms wall [LJ $(12-6)$] (Hu et al. 2015), which leads to the failure of classical L–B mixing rule in tackling solid–fuid interactions. Therefore, we present the CG methane model to solve the problem (the formula of CG potential function depends on the atoms wall). Meantime, the LJ (12- 6) interatomic pair potential is commonly used in MD simulations of solid–liquid boundaries (Karniadakis et al. [2006;](#page-16-8) Sadus [2002](#page-16-38))

$$
U_{\rm MS} = 4\varepsilon_{\rm MS} \left(\left(\frac{\sigma_{\rm MS}}{r} \right)^{12} - \left(\frac{\sigma_{\rm MS}}{r} \right)^6 \right). \tag{3}
$$

The CG methane model maps one methane molecule onto a single particle with its center of mass as the interaction point. The interactions of CG methane particles are implicitly incorporated into the effective pair interaction potential, given as

$$
U_{\rm CG} = 4\varepsilon_{\rm CG} \bigg(\left(\frac{\sigma_{\rm CG}}{r}\right)^{12} - \left(\frac{\sigma_{\rm CG}}{r}\right)^6 \bigg). \tag{4}
$$

The parameters of CG potential are determined by the relative entropy minimization method (Shell [2008](#page-16-34)) in the bulk methane fuid under NVT ensemble. The obtained parameters of the CG potential are $\sigma_{\text{CG}} = 3.645 \text{ Å}$, $\varepsilon_{\text{CG}} = 1.329 \text{ kJ/mol}$ at $\rho = 377.15 \text{ kg/m}^3$ and $T = 140 \text{ K}.$ The potential of mean force $(W(r) = -k_B T \ln g(r))$ and RDF of CG model are given in Fig. [2.](#page-3-1) It can be seen that the results of CGMOPLS are in better agreement with the corresponding fully atomistic model than unit atom LJ model (Poling et al. [2001](#page-16-39)). It indicates that we can obtain the ideal interactions of wall–fuid using the classical L–B mixing rule coupling the corresponding CG model (Kong [1973](#page-16-12)).

Finally, we apply the classical L–B mixing rule to determine the parameters of wall–fluid σ_{MS} and ε_{MS} for methane–silicon interactions

Fig. 2 Comparison of potential of mean force and RDFs of CGMOPLS with the results obtained MOPLS and unit atom model at given states points ($\rho = 377.15 \text{ kg/m}^3$ and $T = 140$ K)

$$
\sigma_{\rm MS} = \frac{\sigma_{\rm CG} + \sigma_{\rm SS}}{2}, \quad \varepsilon_{\rm MS} = \sqrt{\varepsilon_{\rm CG} \cdot \varepsilon_{\rm SS}}.
$$
 (5)

2.3 Simulation details

In this work, we use non-equilibrium MSMD to study the effects of wall roughness on methane fuid in nano-channels. Our system consists of 1440 (λ_1) $(1500 \ (\lambda_i, A_1), 1560 \ (\lambda_i, A_2), 1620 \ (\lambda_i, A_3), i = 2, \ldots, 5)$ fuid methane molecules with different rough walls and is bounded by 2160 (A_1) (2400 (A_2) , 2640 (A_3)) silicon atom walls which are subjected to an additional harmonic potential with respect to an ABAB stacking (Kamal et al. [2013](#page-16-35)) (shown as example (A_2, λ_2) in Fig. [1\)](#page-2-1) site \mathbf{r}_{eq} ,

$$
u(|\mathbf{r}(t) - \mathbf{r}_{\text{eq}}|) = \frac{1}{2}k_w(|\mathbf{r}(t) - \mathbf{r}_{\text{eq}}|)^2,
$$
 (6)

where $\mathbf{r}(t)$ is the position of a boundary particle at time t . The rigidity of the wall is determined by the force constant k_w (= 72 ε _S/(2^{1/3} σ_S^2)), which is calculated by the second derivative of the interaction LJ (12-6) potential of silicon atoms at $r = 2^{1/6}\sigma_s$ (Liem et al. [1992](#page-16-40)), where the parameters are $\sigma_S = 3.826$ Å, $\varepsilon_S = 1.6885$ kJ/mol, and the density of silicon is 2329 kg/ $m³$ (Hu et al. [2015](#page-15-20)). The system is periodic along the *x*- and *y*-directions in all cases, while in the *z*-direction, the distance, L_z (= 12.4 σ), between the two silicon atom walls, is large enough for methane molecules to penetrate beyond the wall surface layers.

In the present study, our method is essentially different from that employed by Markesteijn et al. [\(2012\)](#page-16-41) to study a complex water molecule fuid using the Poiseuille flow in solving the problem of interaction for wall–fluid. We apply the CG methane model to solve the problem of interactions of wall–fuid rather than simple ignoring the charge force and H atom interactions adjacent to wall (less than r_{cut}). And more specifically, the formula of CG potential function of complex fuid relies on solid wall. For example, the LJ (12-6) potential is employed as the CG methane potential in this work, because the potential function of solid silicon atom is LJ (12-6) potential (Hu et al. [2015](#page-15-20)).

In order to avoid compressibility effects, the external driving force $f_{ex} = 0.1$ (ε/σ) is employed along the *x*-direction only to drive the fow in different roughness of nano-channel walls (Jiang et al. [2016a](#page-16-7)). All intermolecular interactions are subject to a continuous force (or continuous energy) cutoff radius of $r_{\text{cut}} = 2.5 \sigma$. The orientational coordinates of the methane tetrahedral are expressed in terms of quaternion parameters, and the center of mass motion of methane molecules is integrated via using the fourth Predictor–Corrector method (Allen and Tildesley [1989](#page-15-10); Frenkel and Smit [2001;](#page-15-21) Hansen and McDonald [1990;](#page-15-22) Rapaport [2004\)](#page-16-42). To control the temperature of

system, the NVT ensemble with Nosé-Hoover thermostat is employed. Whether the thermostat follows the equipartition theorem is checked, by comparing the thermal kinetic energy per methane molecule in *y*- and *z*-directions

$$
mv_{y}^{2}/2 = k_{B}T/2,
$$
\t(7)

$$
mv_z^2/2 = k_\text{B}T/2,\tag{8}
$$

where m , k_B , T , v_y and v_z denote the mass of molecule, Boltzmann constant, temperature, velocity of *y*- and *z*-directions, respectively. This can ensure that the thermostat effect is observed in each direction due to the intermolecular interactions, although *x*-direction is not explicitly considered (Bhadauria and Aluru [2013](#page-15-23)). The scaling parameters $\sigma = 4.01$ Å and $\varepsilon / k_B = 142.87$ K are used. The time step is $\Delta t = 0.001$ (1.3 × 10⁻¹⁵ s), the first 2.0×10^5 MD time steps are excluded from the statistical analysis, and the relevant information of methane fuid was collected by further 7.0×10^5 time steps. The streaming velocity profles, equilibrium atom (C and H) distribution profles and temperature profles are calculated by dividing different channel width values $(L_z + 2A_i$ $(i = 1, 2, 3)$ in 400 bins. The temperature profles are calculated in each bin across the nano-channel using the equation (Delhommelle and Evans [2001a,](#page-15-12) [b;](#page-15-13) Kasiteropoulou et al. [2012](#page-16-0))

$$
T = \frac{m}{3Nk_{\rm B}} \sum_{i=1}^{N} (\mathbf{v}_i - \bar{\mathbf{v}})^2,
$$
 (9)

where *N* is the number of methane molecule; v_i and \bar{v} are velocity of molecule *i* and the corresponding stream velocity (macroscopic flow velocity), respectively. In order to observe the effect of different rough nanochannel walls on the localization properties of methane fuid, the three-dimensional C and H atoms number density profles and kinetic energy distribution maps are evaluated as local values at various *xoz* planes of the nano-channels. To obtain these results, the domain is divided into $n_x \times n_y \times n_z = (24 \times 10 \times 50)$ bins in the whole channel (include the wall) with each volume $V_{\text{bin}} = (L_x/n_x) \times (L_y/n_y) \times (H/n_z)$. The localization kinetic energy, *W*bin, is computed by the following expression:

$$
W_{\text{bin}} = \frac{1}{2} m_{\text{bin}} \langle \mathbf{v}_{\text{bin}} \rangle^2, \tag{10}
$$

where $m_{\text{bin}} = mn_{\text{bin}}$ and $\langle v_{\text{bin}} \rangle$ are mass and average velocity in the bin, respectively. n_{bin} is the number of molecule in the bin. All the simulation program codes are developed using C++ on Windows operating systems (Frenkel and Smit [2001;](#page-15-21) Rapaport [2004\)](#page-16-42).

3 Results and discussion

3.1 Fluid localization properties

In order to investigate the effects of wall roughness on the methane fuid in different nano-channels, the three-dimensional number density contours ($n_v = 6$) of C and H atoms are shown in Figs. [3](#page-5-1) and [4](#page-6-0). Contour plots of the number density distribution of C and H atoms are obtained as values averaged in time inside the nano-channels. It is noted that the number density distribution of methane molecule is equal to that of C atom. Figures [3](#page-5-1) and [4](#page-6-0) illustrate that the number densities of C and H atoms present strong oscillations in density near the walls and consist of a series of number density islets. The results are similar to the research of Sofos et al. for liquid argon through krypton nano-chan-nels (Sofos et al. [2009c](#page-16-26)). For $\lambda = 1.07 \sigma$, Figs. [3](#page-5-1)a(1), b(1), $c(1)$ and [4](#page-6-0)a(1), b(1), c(1) show a series of localization number density island close to wall. The reason is that the cavities ($\lambda = 1.07 \sigma$) are too small to contain a methane molecule, and therefore, each methane molecule can straightly across these small cavities without anchoring. At the protrusion domain, however, the methane molecules suffer larger repulsive force from the wall atom than the small cavities. Moreover, the interaction force exhibits periodic variation adjacent to the rough nano-channel walls, which results in the local number densities of atoms displaying cyclic variation. For $\lambda = 2.15 \sigma$, Figs. [3a](#page-5-1)(2), b(2) and c(2) and $4a(2)$ $4a(2)$, $b(2)$, $c(2)$ exhibit a series of regular local number density island at the protrusion domain of rough nanochannel walls. One possible reason is that the strength of wall–fuid interaction increases when the molecules come across the protrusion. Moreover, we fnd increasing localization densities inside the cavities as the wall amplitude (groove height) increases. It means that the trapped methane molecules become difficult to escape from the confined cavities. For $\lambda \geq 4.31 \sigma$, the local number densities of C and H atoms decrease with the increase in wavelength λ for same value of amplitude from Figs. $3a(3)-a(5)$ $3a(3)-a(5)$, $b(3)-a(5)$ b(5), c(3)-c(5) and $4a(3)-a(5)$ $4a(3)-a(5)$, b(3)-b(5), c(3)-c(5) inside the cavities of rough wall. It indicates that the fuid atom localization inside the cavities increases, while the protrusion length ($\lambda \geq 4.31 \sigma$) decreases, i.e., the roughness of nano-channel wall has a major infuence on the fuid atom localization distribution.

The effect of wall roughness on the C and H atoms number density profles as a total average value for all nanochannels cases is presented in Fig. [5](#page-7-0). In general, at lower smooth wall, all nano-channels present the same C atom localization with a peak in the profle occurring at distance of about 1.4 σ from the lower wall limit. However, the H atom number density shows diversity in the profles near

Fig. 3 Three-dimensional C atom number density plots for different periodic roughness of the *upper walls*. *Lighter colors* denote increased fuid atom localization, and the *blue regions* represent the solid wall $(n_y = 6)$

Fig. 4 Three-dimensional H atom number density plots for different periodic roughness of the *upper walls*. *Lighter colors* represent increased fuid atom localization, and the *blue regions* denote the solid wall $(n_v = 6)$

wall except the smallest wavelength ($\lambda = 1.07 \sigma$). Moreover, the localization number density peak value of smooth wall is larger than that of rough nano-channel walls, which indicates that the strength of mean wall–fuid interactions of the rough nano-channel wall is smaller than the smooth wall. For $\lambda_1 = 1.07 \sigma$, C atom number density profiles are practically identical with different amplitudes in Fig. [5.](#page-7-0) However, H atom number density profles increase as the amplitude value (groove height) increases, which shows the H atom number density distribution is very sensitive to strength of mean wall–fuid interactions. The similar conclusions of fuid density distribution are reported by Giannakopoulos (2014) for studying the density variations by non-equilibrium MD simulations in nano-channel flows. Furthermore, the C (H) atom localization number densities have signifcantly diversity near rough nano-channel walls with same wavelength $(\lambda_i, i = 2, 3, 4, 5)$ and different amplitudes (A_1, A_2, A_3) . And we observe that the positions of second or third peak values of H atom localization number density profle are signifcantly different adjacent to rough upper wall. These numerical results show that the C (H) atom distribution of methane molecule depends on the roughness (amplitudes) of nano-channel walls. Besides, we fnd increasing anisotropy of methane molecule as the values of rough amplitude increases at the same wavelength (or wavelength decreases at the same amplitude).

In order to exhibit the methane fuid molecules trapped into cavities of rough nano-channel walls, characteristic trajectories of the trapped methane molecules in the *xoz* plane for $\lambda_2 = 2.15 \sigma$ are shown in Fig. [6](#page-8-0). It can be seen that the average residence time of methane molecules inside the cavities increases with the increase in the amplitude (protrusion height). Characteristic trajectories for $A_2 = 1.07 \sigma$ $A_2 = 1.07 \sigma$ $A_2 = 1.07 \sigma$ are also shown in Fig. 7. We observe that the methane molecules inside the cavities cost a long time to escape from the confned by the short wavelength (groove width) at same amplitude (protrusion height), which is in good agreement with the published results for fuid argon (Sofos et al. [2009c](#page-16-26)). These results demonstrate that the non-equilibrium MSMD is a credible option for studying the complex methane fuid atom distribution in the rough nano-channels. Furthermore, the numerical results indicate that the trajectories of the trapped methane molecules depend on the roughness of nano-channel walls (wavelength and amplitude).

3.2 Kinetic energy distribution and temperature profles

To study the impact of wall roughness on the localization velocity distribution of methane fuid in nano-channels in detail, the contour plots of kinetic energy obtained from the average values in time inside the nano-channels are given in Fig. [8](#page-9-0) for different roughness of the upper walls. The kinetic energy distributions are suitable for showing the localization distribution of velocity of methane molecule **Fig. 5** Total average C and H atoms number density profles with different amplitudes (A_1, A_2, A_3) and wavelengths $(\lambda_1, \lambda_2, \lambda_3, \lambda_4, \lambda_5)$. Note that the conclusions obtained from the molecule inside the nanochannels include the trapped molecules into the cavities

inside nano-channels from Eq. ([10\)](#page-4-0). In all the numerical results, adjacent to the smooth wall, the kinetic energy distributions do not obviously change. Moreover, we observe a series of kinetic energy small islands near the rough upper walls. These results show different kinetic energy distributions inside every cavity of rough upper walls, which is attributable to the mobility of molecule randomness. However, the kinetic energy distributions present the symmetry in the interior of nano-channels. It indicates that the localization velocity distribution approaches the parabolic velocity profle, which is similar to the macroscopic fluid for Poiseuille flow.

When $\lambda_1 = 1.07 \sigma$, the localization kinetic energy distributions are exhibited in Fig. [8a](#page-9-0)(1), b(1), c(1). We observe that the regularity of kinetic energy small islands gradually increases with the increase in amplitude, and low kinetic energy (the lighter regions) domain increases as the amplitude increases. It indicates that the force of methane molecules obtained from wall atoms decreases, while the value of amplitude increases.

It can be seen from Fig. $8a(2)$ $8a(2)$, $b(2)$, $c(2)$ that the values of localization kinetic energy of cavities decrease as the amplitude increases ($\lambda_2 = 2.15 \sigma$). It denotes that the velocity of trapped methane molecule decreases, while it was trapped in the depth of cavities. And the trapped molecules always try escaping from the cavities, which will consume some kinetic energy.

Figure [8a](#page-9-0)(3), $b(3)$, 8-c(3) shows the localization kinetic energy for $\lambda_3 = 4.31 \sigma$. We observe that there exhibits at least one region of high kinetic energy (the darker regions) inside every cavity, and the number of regions of high kinetic energy increases with the increase in amplitude. It means that the angular velocity of methane molecule becomes larger in the cavities, and at least one attempts to accumulate much more kinetic energy (from other molecules or wall atoms) for escaping from the confned depth cavity (large amplitude).

For $\lambda_4 = 6.45 \sigma$, we find that there are many regions of high kinetic energy (the darker regions) inside every cavity, and these regions of high kinetic energy show some

Fig. 6 Snapshots of the trapped fuid atom trajectory from the simulation box in the *xoz* plane for three different values of roughness amplitude *A*1, *A*2, *A*3 with the same wave length $\lambda_2 = 2.15 \sigma$

Fig. 7 Snapshots of the trapped fuid atom trajectory from the simulation box in the *xoz* plane for three different values of roughness wavelengths λ_3 , λ_4 , λ_5 with the same amplitude $(A_2 = 1.07 \sigma)$

regularity as the amplitude increases. The results are given in Figs. $8a(4)$ $8a(4)$, $b(4)$ and $c(4)$. At the same time, the regions of low kinetic energy (the lighter regions) exhibit the cavity adjacent to interior of nano-channels. It indicates that the methane molecule would be easy to escape the cavity. And their kinetic energy reaches local minimum when they escape from the cavity.

Figure [8a](#page-9-0)(5), $b(5)$ and $c(5)$ demonstrates that the regions of high kinetic energy are observed adjacent to the wall inside cavity for $\lambda_5 = 12.84 \sigma$. And the regions **Fig. 8** Kinetic energy contour plots for different periodic roughness of the *upper wall*. The *blue regions* are the *solid wall* (the unit of energy is ε, $n_v = 6$

of low kinetic energy (the lighter regions) increase with the increase in amplitude inside the cavity near interior of nano-channels, due to the fact that the wavelength is too long to well confne methane molecules to stay inside the cavities.

To observe the effect of the nano-channel walls roughness on the temperature of methane fuid, the temperature profles are calculated using Eq. [\(9](#page-4-1)) and are illustrated in Fig. [9](#page-10-0). It can be found that the temperature adjacent to smooth walls is higher than the system temperature. And the temperature presents complex change near the rough upper nano-channel walls. The results are similar to the simulation results of Kasiteropoulou et al. [\(2012](#page-16-0)) using the dissipative particle dynamics method. We attribute it to the complex wall–fuid interactions which signifcantly infuence on the atom number density distributions (see Figs. [3,](#page-5-1) [4,](#page-6-0) [5](#page-7-0)) and kinetic density distributions (see Fig. [8](#page-9-0)). Moreover, we also observe that the values of temperature in the central part of the nano-channel are slightly less than 140 K. The numerical results are in good agreement with the reported results of Delhommelle and Evans ([2001a](#page-15-12), [b\)](#page-15-13) via the non-equilibrium MD simulations. The reason may be attributed to the statistical errors and the constant-temperature method which controls the temperature by comparing the thermal kinetic energy per methane molecule in *y*- and *z*-directions. All the results of temperature profles also indicate that the non-equilibrium MSMD is reasonable and credible to study the methane nano-fuidic systems within the rough silicon atom walls.

3.3 Velocity profle and slip length

The velocity profiles of v_x averaged in time and space are given in Fig. [10](#page-11-0) for different rough nano-channel walls. For $\lambda_1 = 1.07 \sigma$, the values of maximum velocity are not signifcantly affected by the magnitude of the amplitude. And the velocity profles do not obviously change near the rough wall, since the cavity is too small to contain one methane molecule, where the repulsive force decreases when the methane molecules are adjacent to the upper nano-channel walls. The results are similar to the liquid argon through krypton nano-channels (Sofos et al. [2009c\)](#page-16-26). For the other values of wavelength, the values of maximum velocity slightly change as the amplitude increases (or decreases). However, the values of maximum velocity are obviously affected by the wavelength at the same amplitude, i.e., the values of maximum velocity increase with the increase in wavelength ($\lambda \neq \lambda_2$). When $\lambda_2 = 2.15 \sigma$, the value of maximum velocity is obviously larger than other values ($\lambda \neq \lambda_2$), which indicates that the effect of wall roughness ($\lambda = \lambda_2$) on the mobility of molecule is significant. Moreover, for $\lambda \neq \lambda_1$, the values of velocity near rough walls present an irregular fuctuation, which reveal that the trapped fluid molecules suffer from

Fig. 9 Total average temperature profles with different amplitudes (A_1, A_2, A_3) and wavelengths $(\lambda_1, \lambda_2, \lambda_3, \lambda_4, \lambda_5)$. Note that the conclusions obtained from the molecule inside the nano-channels include the trapped molecules inside the cavities

complex wall–fuid interaction in the cavities of upper wall. Furthermore, the velocity profles obtained from the non-equilibrium MSMD simulations are similar to the Poiseuille flow velocity profile, with slight differences adjacent to the walls. It indicates that the mainstream regime of the methane nano-fows through the rough nano-channels obeys the continuum mechanics characterized by the Navier–Stokes equation. The velocity values fuctuate adjacent to the rough nano-channel walls. It means that the methane fuid molecules suffer from the resistance force of protrusion while they are confned to the cavities.

Furthermore, as shown in Fig. [11](#page-11-1) we can obtain the slip length l_s [smooth (S), rough (R)] by extrapolating the velocity profle from the position in the fuid [with one atomic distance (D) from the smooth and rough solid surfaces] to where the velocity would lose the continuum mechanics characterized. It is noted that the slip length l_s is given as follows (Cao et al. [2006b](#page-15-16)):

$$
l_{\rm s} = \frac{V_{\rm s}}{\dot{\gamma}},\tag{11}
$$

where V_s is slip velocity, and $\dot{\gamma} = dV_s/dz|_{z=0}$ is the shear rate.

The slip lengths of smooth and rough solid surfaces are given in Fig. 12 using Eq. (11) (11) . The comparison of the slip length of smooth wall is clearly larger than those of the rough wall at same wavelength and amplitude. And the slip length difference of between smooth wall and rough wall decreases with the increase in wavelength. It should be noted that V_s and $\dot{\gamma}$ are calculated by average the velocity and shear rate adjacent to the smooth (rough) wall. These numerical predictions are in quantitative agreement with the results of the argon fuid through the rough micro- and nano-channels (Cao et al. [2006a](#page-15-19), [b](#page-15-16); Sofos et al. [2009c](#page-16-26)). One possible reason is that the complex interaction of wall–fuid makes some trajectory of methane molecules more convoluted when the fuid molecule escapes from the cavities of rough wall. Moreover, the slip length $l_s(R)$ decreases with the increase in amplitude, which indicates the velocity values of fuid decrease near rough wall, while the amplitude increases. This reason should be attributed to the complex interaction of wall–fuid, which leads to the increased friction factor with the increase in the protrusions of height (amplitude) at same wavelength. The similar results can be found in the literature (Liakopoulos et al. [2016](#page-16-3)). Though the slip length $l_s(S)$ slightly increases with increased amplitude, it approaches a constant within calculation error at given value of amplitude. It demonstrates that the velocity values of methane fuid molecules are like near a smooth wall, since the interaction of wall–fuid does not signifcantly change. We attribute the slight difference to the fundamental statistical noise.

In a word, the effect of wall roughness is important in predicting the localization properties of the methane fuid in nano-channels. Based on the detailed investigation of three-dimensional number density (C and H atoms) distribution presented in Figs. [3](#page-5-1) and [4](#page-6-0), in connection with the characteristic trajectories of the trapped methane molecules (Figs. [6,](#page-8-0) [7](#page-8-1)), three-dimensional kinetic energy distributions (Fig. [8\)](#page-9-0), temperature profles (Fig. [9\)](#page-10-0) and total average streaming velocity profles (Fig. [10\)](#page-11-0) inside nano-channels, there is conclusive evidence that methane fuid molecules are trapped inside wall cavities and this effect becomes more pronounced as the groove characteristic wavelength decreases or amplitude increases. The slip length $l_s(R)$ is less than $l_s(S)$. And $l_s(R)$ decreases as amplitude increases. These results also further indicate that the non-equilibrium MSMD is an effective methodology to investigate the impact of the wall roughness on the fuid atom localization distribution, kinetic energy

Fig. 10 Total average streaming velocity profles plotted over the whole channel region $(L_z + 2A_i \ (i = 1, 2, 3))$. *Solid lines* obtained by ftting 280 simple points in the middle of nano-channels. For the sake of brevity and readability, the velocity profle was given by shift 0.5 nm in *z*-direction

30

 25 velocity (m/s) 20 $l_e(R)$ 5 $0\frac{1}{6}$ $\overline{2}$ $\overline{3}$ $\overline{4}$ 5 distance (nm)

Fig. 12 Variation of the slip length l_s (L_z) [smooth (S), rough (R)] as a function of wavelength and amplitude; the bars are calculation error. The lines are drawn as a guide to the eye

Fig. 11 Definition of the length of slip $l_s(S)$ and $l_s(R)$. S and R denote the smooth wall and rough wall, respectively. The *black solid line* is a guide for the eye

distribution, temperature profle, velocity profle and slip length of complex methane flow in rough nano-channels. To further explore the effect of the nano-channels wall roughness on the Poiseuille fow behavior of methane

fluid, we investigate the variation of diffusion coefficient and RDFs in nano-fuidics.

3.4 Diffusion coeffcient

Because of the strong layering of fuid atoms near the nanochannel walls, methane fuids are inhomogeneous. Classical fuid transport theories do not account for the inhomogeneity of the molecule fluid, and the diffusion coefficients in rough nano-channels can refect the diffusion capacity and mass transfer for methane fuids. The channel diffusion coefficient is obtained from the Einstein expression (Diestler et al. [1991;](#page-15-24) Rapaport [2004](#page-16-42))

$$
D = \lim_{t \to \infty} \frac{1}{2dNt} \left\langle \sum_{i=1}^{N} \left(\mathbf{r}_i(t) - \mathbf{r}_i(0) \right)^2 \right\rangle, \tag{12}
$$

or the Green–Kubo relation

$$
D = \frac{1}{dN} \int_0^\infty \left\langle \sum_{i=1}^N \left(\mathbf{v}_i(t) \cdot \mathbf{v}_i(0) \right) \right\rangle dt, \tag{13}
$$

where N , t , d , \mathbf{r} , \mathbf{v} are the numbers of molecule, calculation time, dimensionality of the system, position and velocity of molecule, respectively.

In order to use the Einstein expression to study the impact of the rough nano-channel walls on diffusion coeffcient of methane fuid, we exclude the part of displacement that is due to the macroscopic flow velocity (\bar{v}) in this work (Bitsanis et al. [1987\)](#page-15-25). Moreover, we also consider the diffusion coefficient as mainly flow direction D_x (*x*-direction of the velocity vector **v**), thermal motion direction D_v (*y*- direction of the velocity vector **v**) and transverse D_z (*z*-direction of the velocity vector **v**) to the fow as (Karniadakis et al. [2006](#page-16-8))

$$
D_{\mathbf{x}} = \lim_{t \to \infty} \frac{1}{2Nt} \left\langle \sum_{i=1}^{N} \left(\mathbf{r}_{i\mathbf{x}}(t) - \mathbf{r}_{i\mathbf{x}}(0) \right)^2 \right\rangle, \tag{14}
$$

$$
D_{\mathbf{y}} = \lim_{t \to \infty} \frac{1}{2Nt} \left\langle \sum_{i=1}^{N} \left(\mathbf{r}_{i\mathbf{y}}(t) - \mathbf{r}_{i\mathbf{y}}(0) \right)^2 \right\rangle, \tag{15}
$$

$$
D_{z} = \lim_{t \to \infty} \frac{1}{2Nt} \left\langle \sum_{i=1}^{N} \left(\mathbf{r}_{iz}(t) - \mathbf{r}_{iz}(0) \right)^{2} \right\rangle, \tag{16}
$$

$$
D = \frac{D_x + D_y + D_z}{3}.
$$
 (17)

The diffusion coefficients $(D_x, D_y, D_z$ and *D*) of methane fuid through different nano-channel wall roughness at $\rho = 377.15 \text{ kg/m}^3$, $T = 140 \text{ K}$ are given in Fig. [13](#page-12-0). It

Fig. 13 Comparison of the diffusion coefficients of methane fluid in the nano-channels with the result as obtained from the different amplitudes *A*1, *A*2, *A*3 with the different wavelengths. The *bars* are calculation error. Lines are guide to eye

can be seen that the variation tendency of diffusion coefficients $(D_x, D_y, D_z$ and *D*) for methane fluid are consistent with different rough nano-channel walls. The diffusion coefficient D_z is smallest $(D_z < D_x < D_y)$, since the velocity value v_z is confined by the wall. The values of diffusion coefficients D_x are very close to D_y ($D_x \approx 0.95D_y$), since they are parallel the channel wall. We attribute this behavior to limited mobility of methane molecules trapping inside the grooves. Meanwhile, the values of diffusion coefficient D_y are adjacent to the bulk methane fluid, e.g., the smallest value $D_y = 85.92 \times 10^{-10} \text{ m}^2 \text{s}^{-1}$ (A_2, λ_2) is about 81% of the bulk value, and the biggest value $D_y = 96.6 \times 10^{-10} \text{ m}^2 \text{s}^{-1} (A_1, \lambda_1)$ is about 91.2% of the bulk value (obtained from the MOPLS model using MD simulation is about $106.1 \times 10^{-10} \text{ m}^2 \text{s}^{-1}$ (Jiang et al. [2016b](#page-16-37))). The diffusion coefficient D is bigger than 80% of the bulk value as $\lambda_i \neq \lambda_2$. These results are similar to those of liquid argon through the nano-channels (Bitsanis et al. [1987](#page-15-25); Karniadakis et al. [2006;](#page-16-8) Sofos et al. [2009b](#page-16-24)).

It indicates that the mass transfer behavior of methane fluid through the nano-channel is significantly affected by the wall surface roughness. For the same value of amplitude $A_i(i = 1, 2, 3)$, all diffusion coefficients arrive at the smallest value at $\lambda_2 = 2.15 \sigma$. And the variation tendency of all diffusion coefficients $(D_x, D_y, D_z$ and *D*) become steady with the change of wavelength from $\lambda_2 = 2.15 \sigma$ to $\lambda_5 = 12.84 \sigma$ for different amplitudes. It is noted that the increasing trend of D_z is obviously different with the increase in amplitude. It means that the trajectories of molecules suffer from the effects of nano-channel wall roughness, due to the fact that the complex interactions of wall– fuid infuence the movement of molecule in the rough nano-channels. The anisotropy of the diffusion coefficients inside rough nano-channel wall is similar to the results of liquid argon in krypton nano-channels (Sofos et al. [2009a](#page-16-23)). We attribute the difference to the effect of wall roughness on the trajectories of molecule inside rough cavity. For $\lambda_1 = 1.07 \sigma$, the variation trend of diffusion coefficients does not signifcantly change with the amplitude. Since the cavity is too small to contain one methane molecule, the repulsive force slightly decreases when the methane molecule is adjacent to the upper nano-channel walls. Thus, the impact of rough wall on methane fuid is not signifcant, while it goes through the rough upper wall, i.e., the diffusion coefficients do not obviously change. For $\lambda_2 = 2.15 \sigma$, we observe that the diffusion coefficients D_x , D_y and D are not significantly different for amplitudes $A_2 = 1.07 \sigma$ and $A_3 = 1.62 \sigma$. Since every cavity only contains one methane molecule, the inner molecules are confned into cavities, and it has only minor effect on the other fuid molecules. Moreover, these results also demonstrate that the diffusion coefficients *D* increase, while wavelength increases (except for λ_1) at given amplitude. One possible reason is that the mobility of molecule is reduced inside the rough cavities, which leads to the decrease in diffusion coefficient in these regions. And the simulation results further show the nonequilibrium MSMD could be used to study the effects of rough walls on the dynamical diffusion properties of methane fuid through the nano-channels.

The intermolecular interactions assume signifcance in the regions of rough nano-channel walls where the discrepancy appears, and the diffusion coeffcients no longer suffice to account for the effect of fluid–fluid intermolecular collisions in these cavities due to the differences in wavelength and amplitude. Next, we will show the variation of RDFs in nano-fuidics.

3.5 Radial distribution function

The structural properties are very important in most nano-fuidic systems. The RDF is a basic measure of the structure of a liquid. It measures the probability density

of fnding a particle at a distance *r* from a given particle position. The RDF is defned by

$$
g(\mathbf{r}) = \frac{1}{\rho N} \left\langle \sum_{i=1}^{N} \sum_{j=1, j \neq i}^{N} \delta(\mathbf{r} - \mathbf{r}_{ij}) \right\rangle, \tag{18}
$$

where *N* and $\rho = N/V$ denote the total number of particles and the number density, respectively. The angular brackets represent a time average. The value of the δ symbol is equal to one, while $\mathbf{r} = \mathbf{r}_{ii}$, otherwise, is zero.

Figure [14](#page-14-0) shows quantitative comparisons of RDFs $(g_{\text{CC}}(r), g_{\text{CH}}(r))$ and $g_{\text{HH}}(r)$ between the bulk systems and rough nano-channels. It can be seen that the values of RDFs $(g_{CC}(r), g_{CH}(r)$ and $g_{HH}(r)$) obtained from the rough nano-channel walls are smaller than those of bulk system, since the methane molecules are confned inside the nanochannels in *z*-direction with the repulsive force of wall atoms. The results of $g_{CC}(r)$ are similar to the equilibrium MD simulation in the pore fuids using LJ potential (Bhatia and Nicholson [2011\)](#page-15-26). For $\lambda_1 = 1.07 \sigma$, the RDFs ($g_{CC}(r)$), $g_{\text{CH}}(r)$ and $g_{\text{HH}}(r)$ of methane fluid do not significantly change with amplitude. For λ_i ($i = 2, 3, 4, 5$), we observe that the values of RDFs $(g_{CC}(r), g_{CH}(r))$ and $g_{HH}(r)$ of methane fuid decrease with the increase in amplitude. And the variation trend decreases with the increase in wavelength, as the averaged constraint of molecules confned inside the cavity decreases as the wavelength increases. For the same amplitude A_2 , the values RDFs $g_{CC}(r)$, $g_{CH}(r)$ and $g_{HH}(r)$ of methane fluid decrease as the value of wavelength increases. However, the reducing trend is not obvious for large value of wavelength. One possible reason is that the molecules confned inside the cavity are easy to escape the constraint of cavity for large wavelength. In a word, the numerical results indicate that the microstructure of methane fuid is signifcantly affected by the roughness of walls. The values of RDFs of methane fuid decrease, while the amplitude increases. The effects of wavelength on the RDFs are not obvious when the wavelength is larger than 2.15σ . Furthermore, the numerical results further demonstrate that the non-equilibrium MSMD method can be indeed used to capture the changing microstructural properties of methane fuid fow in the rough nano-channels with different wavelengths and amplitudes.

4 Conclusions

We have presented non-equilibrium MSMD simulations of methane Poiseuille fow within rough silicon nanochannel walls. And systematic research results show that the presented method not only can well solve the complex problem of wall–fuid, but also could accurately predict the micro-information and dynamic properties of

Fig. 14 Comparison of the radial distribution functions (CC, CH and HH) of methane fuid in the roughness nano-channels with the result as obtained from different amplitudes (*A*1, *A*2, *A*³) and different wave lengths $(\lambda_1, \lambda_2, \lambda_3, \lambda_4, \lambda_5)$

Poiseuille fow for complex fuid. The main conclusions and important fndings are:

1. The non-equilibrium MSMD is an effective method to study the atomic behavior of complex methane fuid in the rough nano-channels. The roughness of silicon wall has an obvious impact on the atom distribution of methane molecule and temperature profles. The anisotropy of methane molecule increases with the values of amplitudes near nano-channel walls.

2. Three-dimensional number density of C (H) and kinetic energy distribution plots reveals inhomogeneity near the solid boundary, especially near the upper rough nano-channels. The number density of C (H) profles and the snapshots of the trapped fuid atom trajectory denote that the fuid molecules tend to be localized inside rough wall cavities. This localization increases, when the cavities become narrower (the width is not less than diameter of fuid molecule) and deeper.

- 3. The numerical results show that the effect of wall roughness on the localization properties of methane fluid is significant. The cavitation of the same dimensions induces different local density, velocity and kinetic energy patterns, while the overall average might be the same. Moreover, the slip length $l_s(R)$ is less than $l_s(S)$, and $l_s(R)$ decreases as amplitude increases.
- 4. Diffusivity has an anisotropic behavior along the three different coordinates, due to the effect of rough nanochannel walls on the mobility of molecule at different directions. And the diffusion coefficients *D* increase, while wavelength increases (except for λ_1) at given amplitude.
- 5. The values of RDFs of methane fuid decrease as the amplitude increases for the same wavelength. The simulation results indicate that the MSMD is a powerful and effective tool to investigate the effects of wall roughness on the microstructural properties of methane fluid flow in the nano-channels.
- 6. All study results recommend that the surface roughness is important and should be considered in investigating the nanostructures and profles of complex methane fuid fow in the rough nano-channels. Therefore, it should be taken into consideration in the design of energy-saving emission reduction nano-fuidic devices, since it affects both flow and mass transfer.

In the future, we will use the non-equilibrium MSMD method to study the effects of rough nano-channels wall with realistic material on local transport properties of complex atomic fuids (such as water, methane, polymer, binary mixture system).

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